

Ink-jet printing of polymer solar cells

Plastic Optoelectronics workshop

June 25th 2010

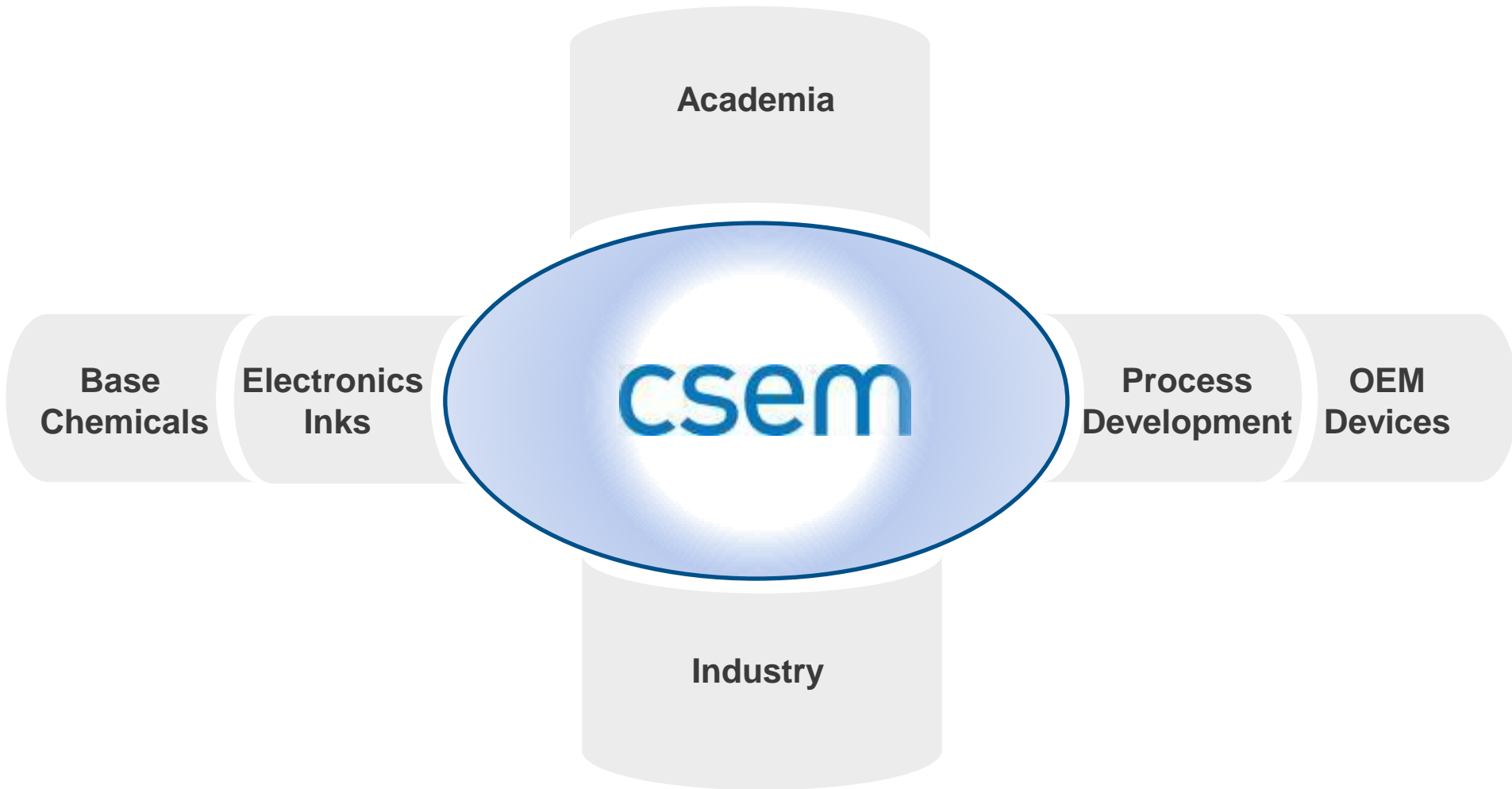
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Section Polymer Optoelectronics, CSEM Basel, Switzerland

Outline

- CSEM
 - Group Polymer Optoelectronics
- Inkjet printing polymer solar cells
 - Novel low bandgap polymer
 - Solvent mixtures
 - Obtaining good uniformity
 - Efficient inkjet printed devices

Role of CSEM in organic electronics



Polymer Optoelectronics

- **Material & Device Optimization**

Solution-processed

- OLED
- OFET
- OPV

- **Integrated Organic Optoelectronic Systems**

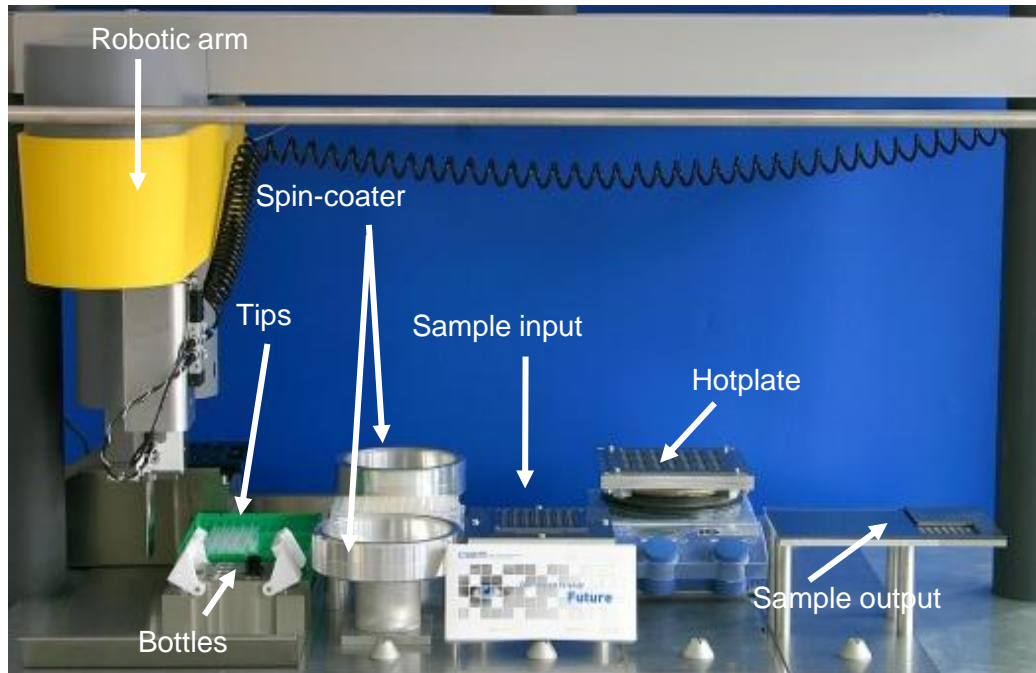
oLEDs & oPDs & oFETs

- **Additive Print Process Development**

- Screen printing
- Gravure printing
- *Inkjet printing*

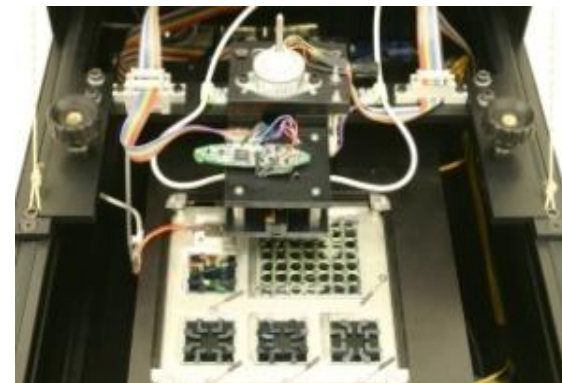
Polymer Optoelectronics

Automated device fabrication tool

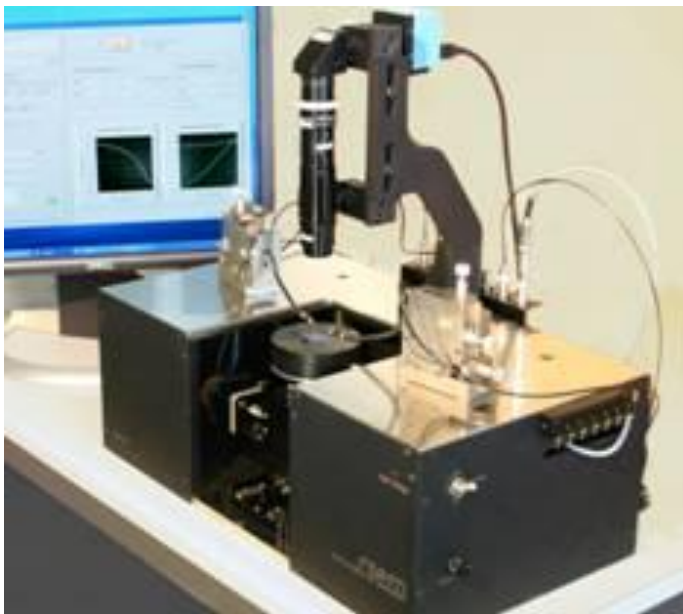


- High throughput fabrication
- Combinatorial testing

Automated OLED and OPV characterisation tool



Polymer Optoelectronics

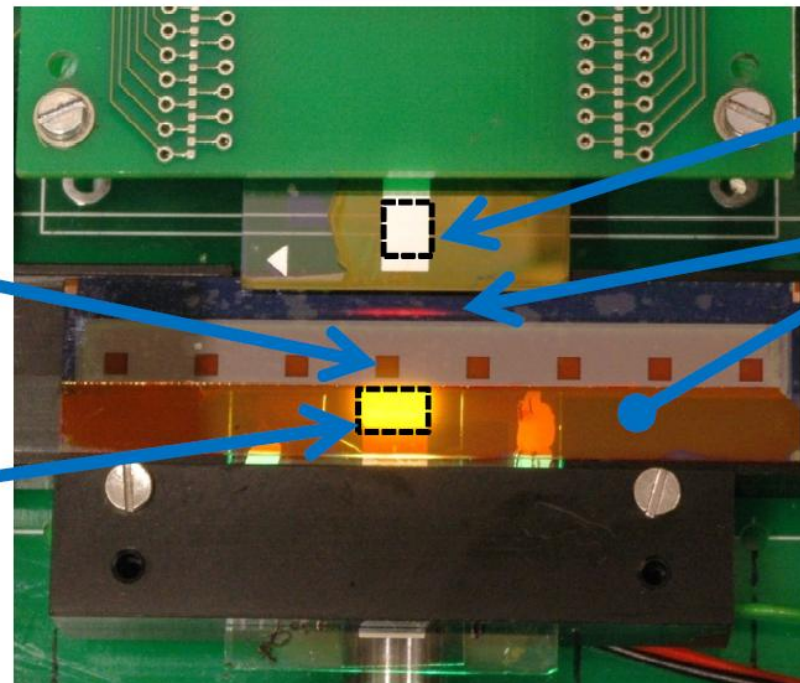


**Automated OFET
characterization tool**

Integrated optoelectronic biosensors

Plasmon
stack (1.8 x
1.8 mm²)

PLED



PPD array

Out coupled light
(0.5 x 3 mm²)

PL material

Inkjet Printed OPV

Why inkjet printing

- Why inkjet printing?
 - *established technology,*
 - *printability in ambient conditions,*
 - *output (up to 150 m²/h),*
 - *low cost,*
 - *flexibility,*
 - *digital patterning,*
 - *mass customization*

POLYMOL project APOLLO

- Project goal: Inkjet printed solar cells with efficiency >5%.

- Project partners :



BASF

Zurich University
of Applied Sciences



ZHAW

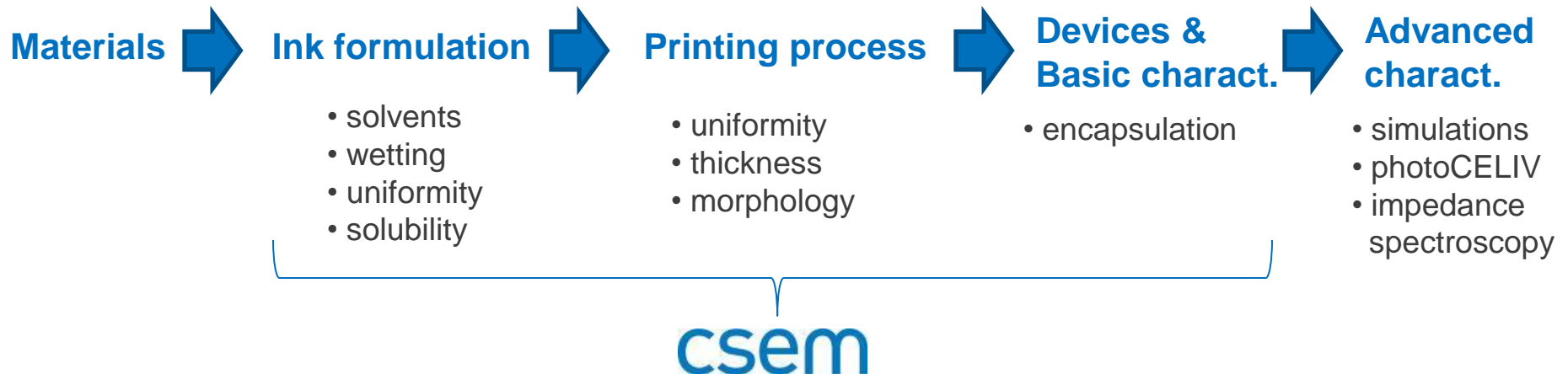


TU Eindhoven



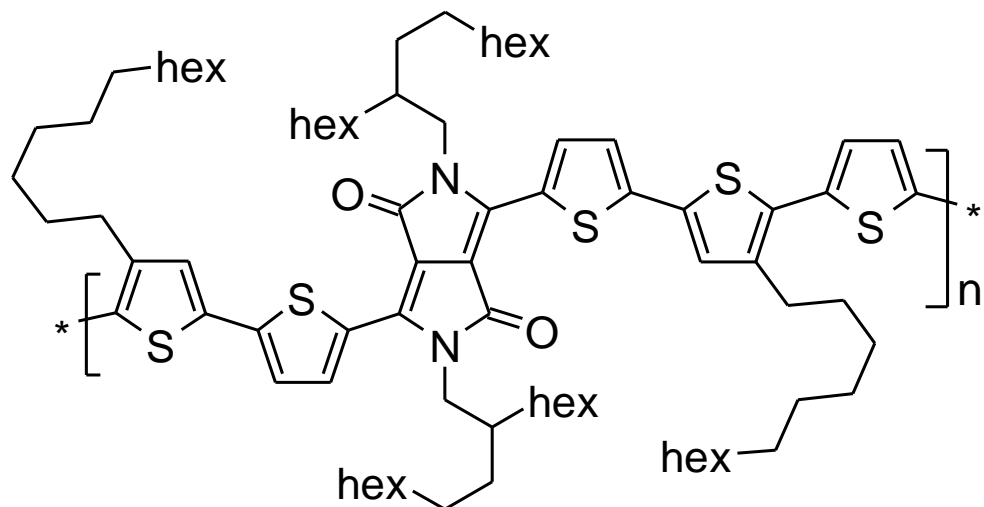
Universitat Jaume I

- Role of CSEM in APOLLO:

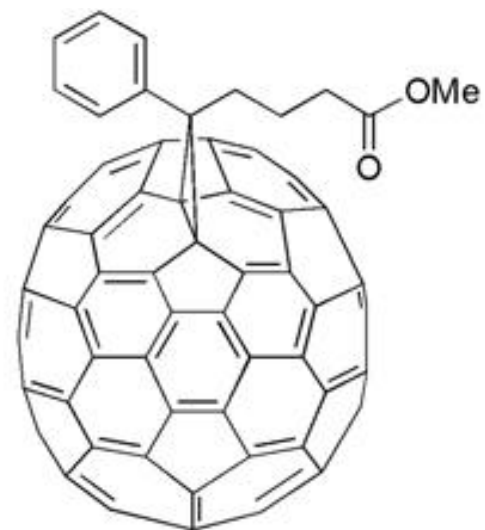


Materials

PT5DPP



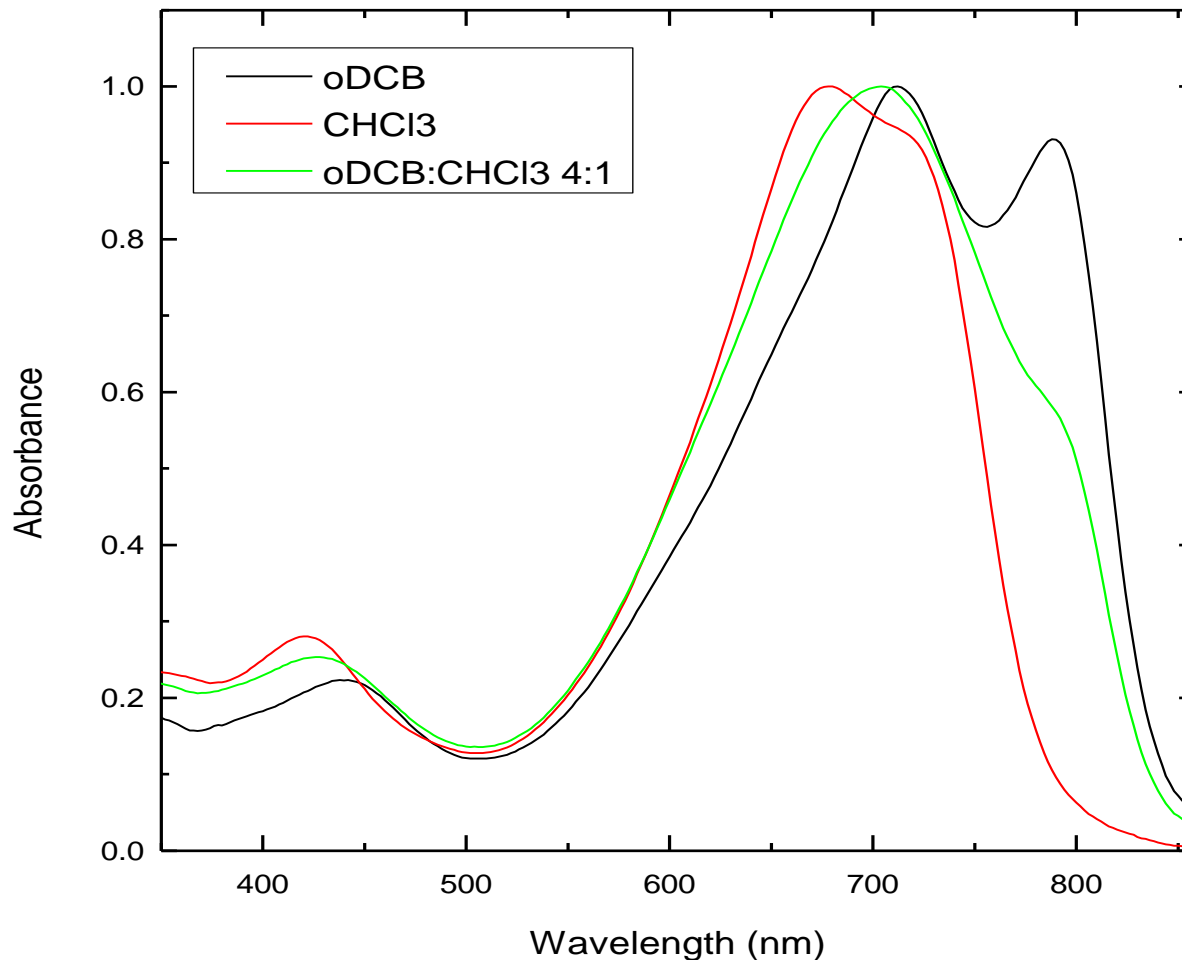
C70PCBM



PT5DPP was made available by BASF



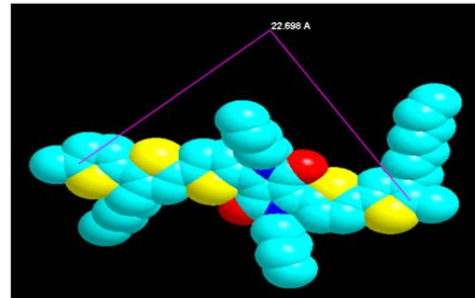
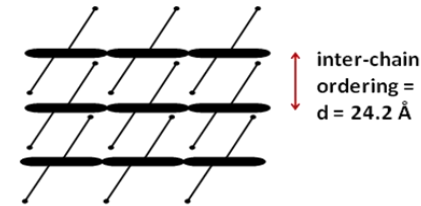
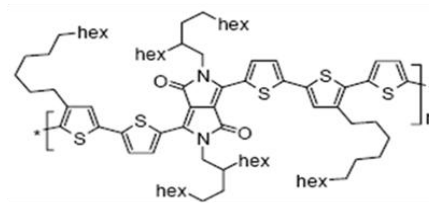
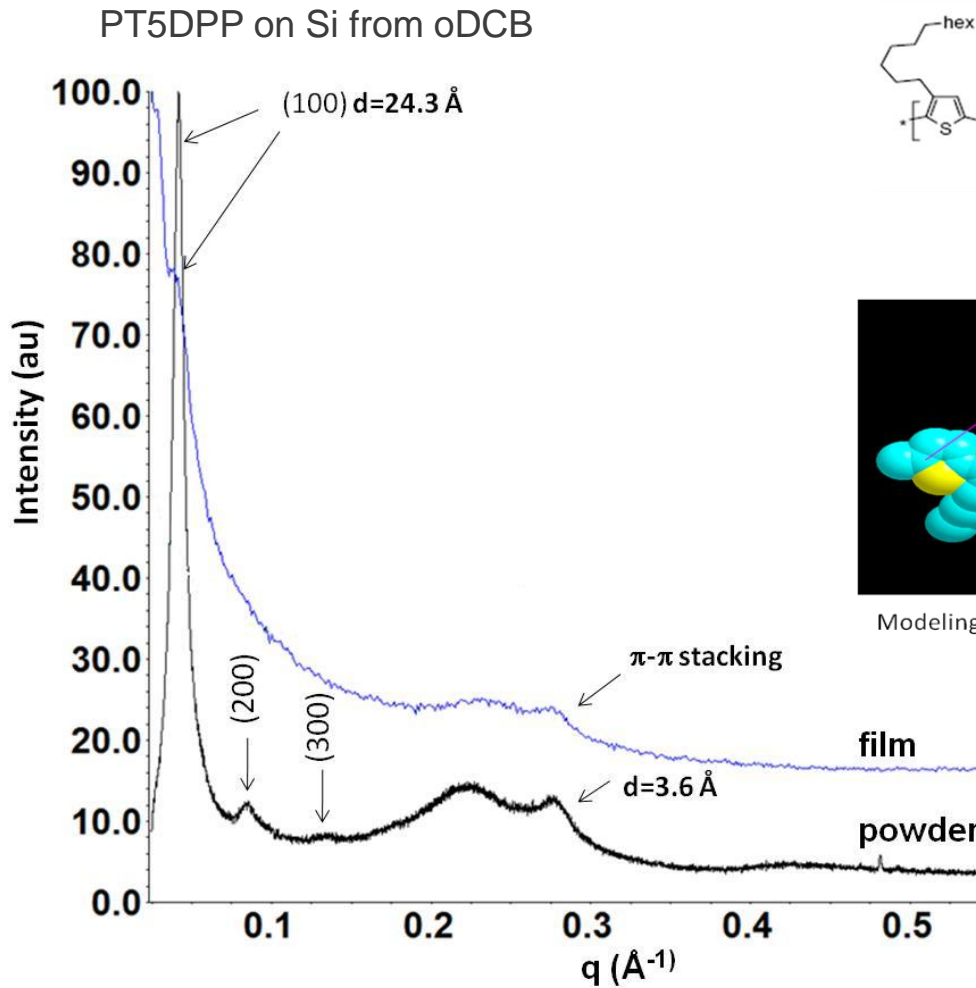
Solubility of PT5DPP



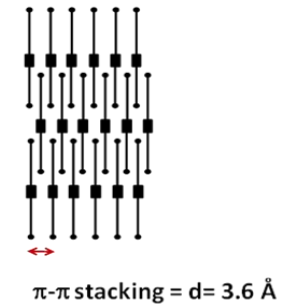
Aggregation in oDCB → favorable

Chloroform: lower boiling point needed for printing at RT

Structural ordering



Modeling of one unit of the 1D polymer

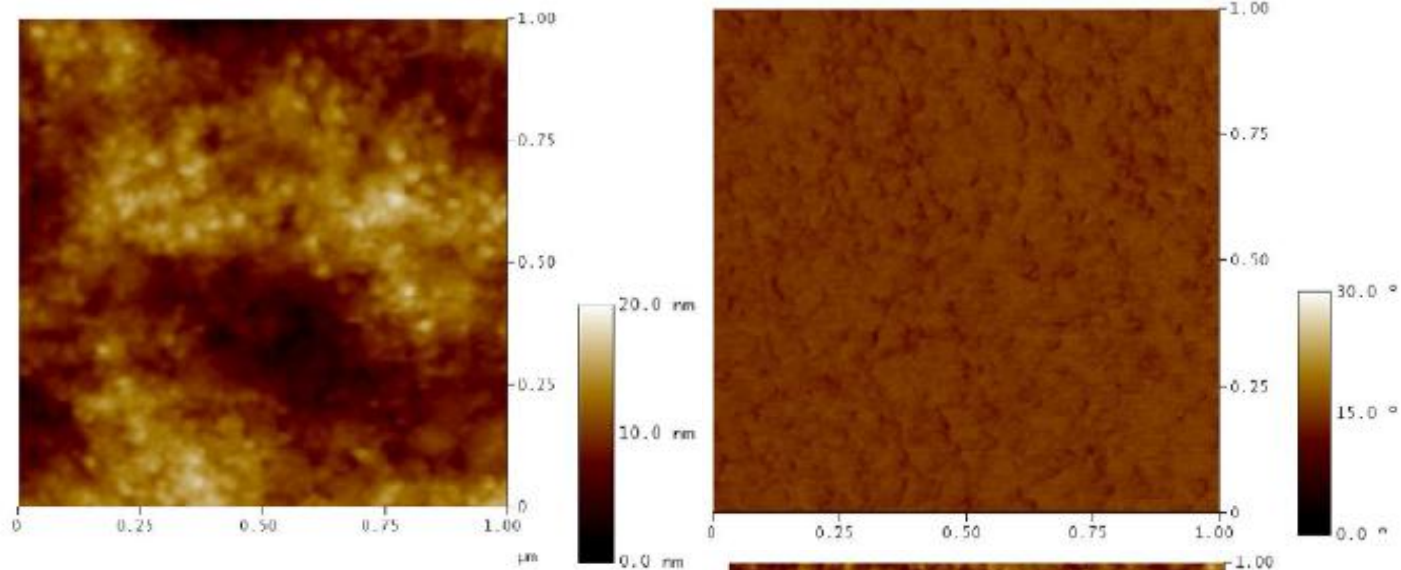


Structural ordering corresponding to the inter-chain spacing and the π - π stacking between the molecules.

Morphology

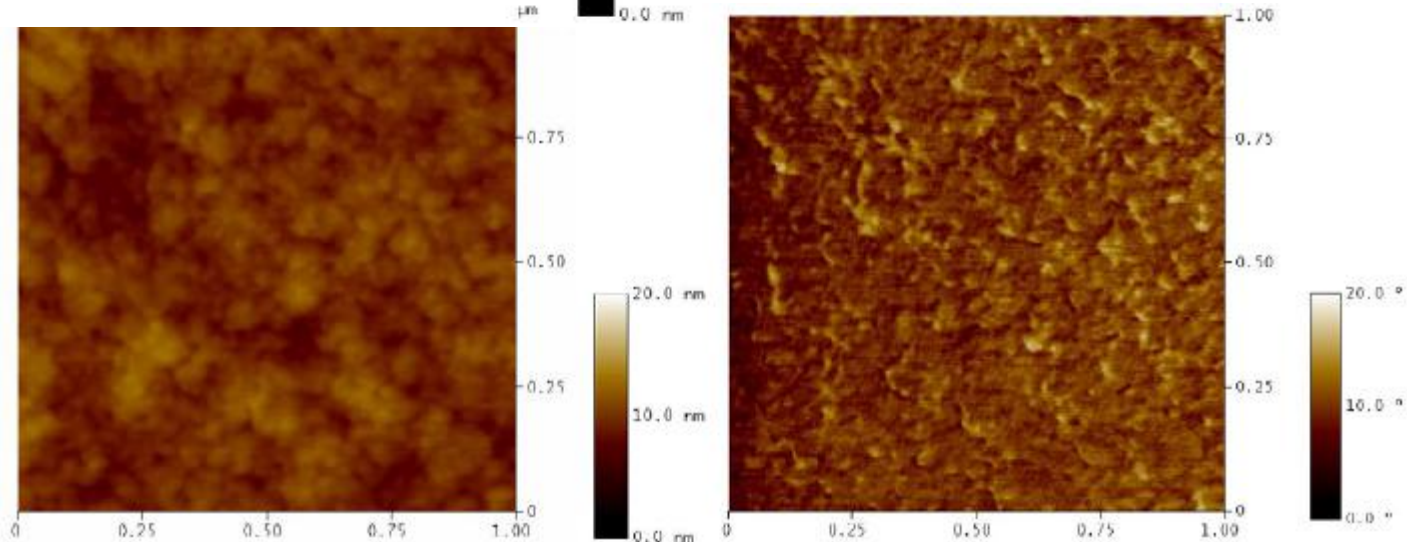
1:4 chloroform:oDCB

Best for printing



4:1 chloroform:oDCB

Best for spin coating



Solvent mixture

Balance between morphology, solubility and layer uniformity

Solubility

- concentration
- drying rate/temperature



Choice
of
solvents

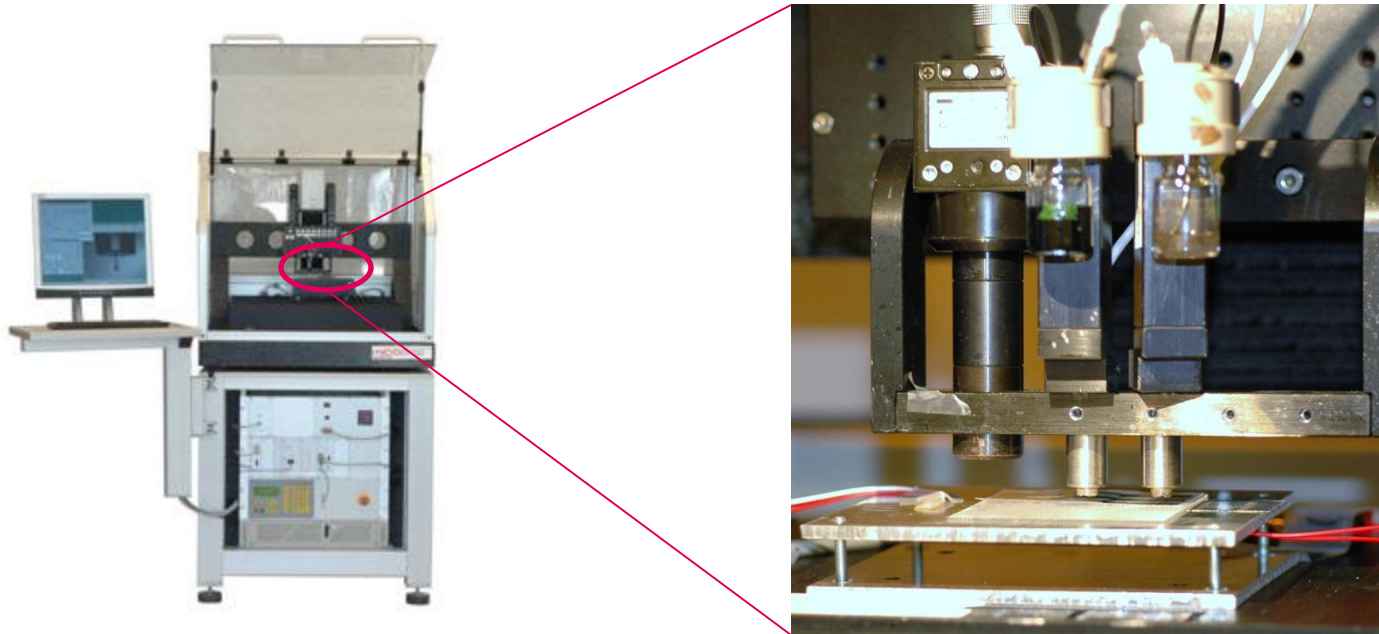
Morphology

- solvent mixture ratio
- drying rate/temperature

Layer uniformity

- viscosity/concentration
- drying rate/temperature

Inkjet printer



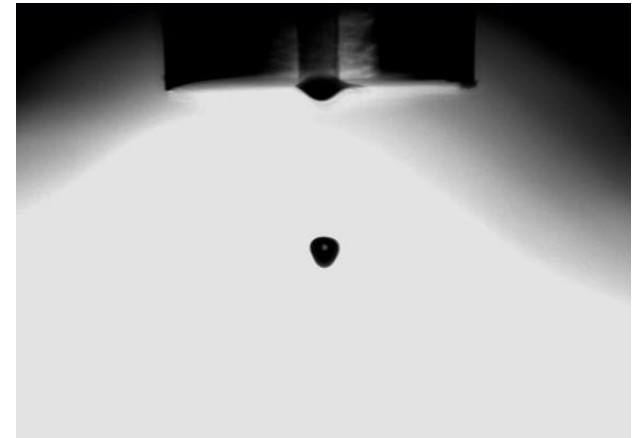
Microdrop single nozzle inkjet printer

- Nozzle diameter 30, 50 and 100 μm
- Heated nozzle tip
- Printing area 200 x 200 mm

Printing process: parameter exploration

Identified key parameters influencing stable drop formation and layer uniformity:

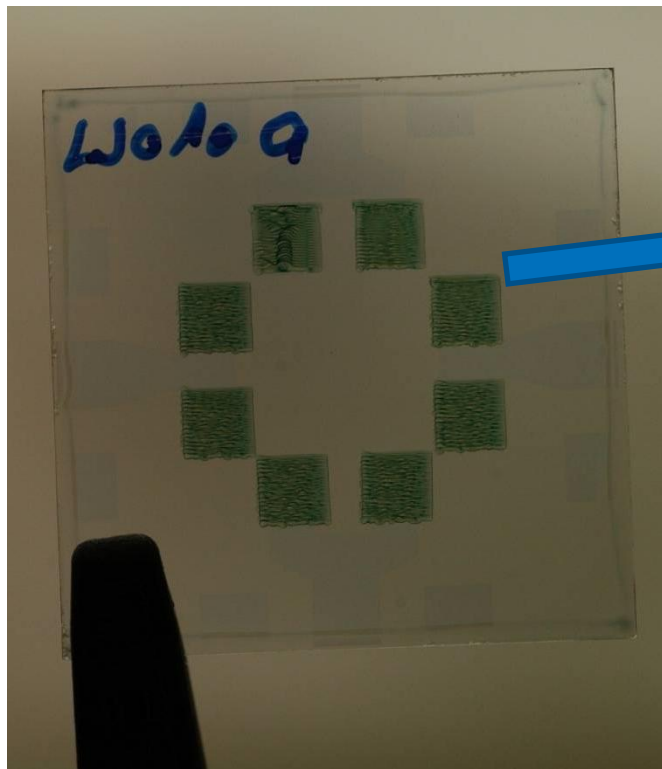
- Drop formation
 - voltage
 - pulse length
 - vacuum pressure
- Layer uniformity
 - dot spacing
 - print head temperature
 - substrate temperature
 - print speed
 - uni/bi-directional printing



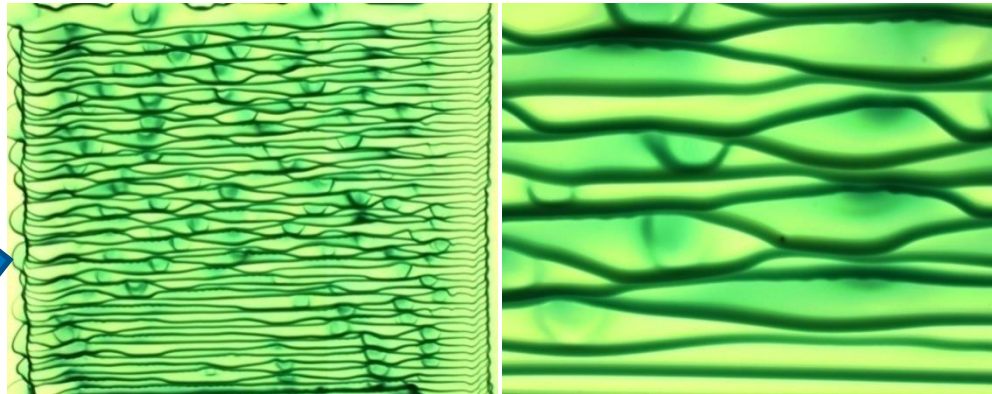
These parameters depend on both solvent and material!

Printing process: obtaining layer uniformity

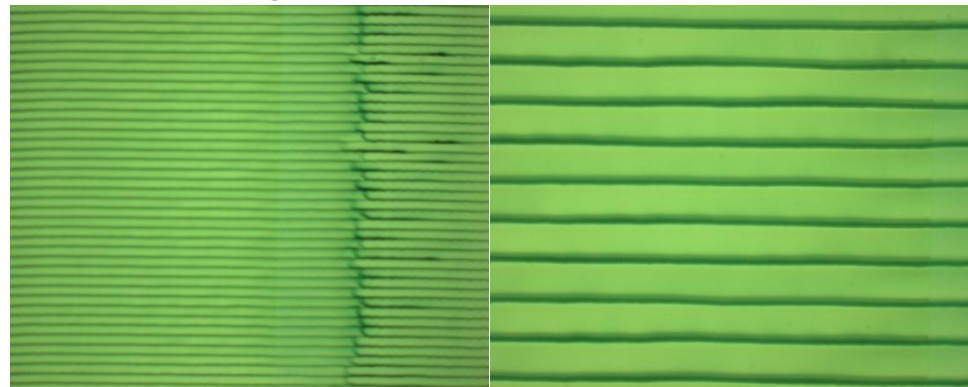
PEDOT coated ITO substrate



Microscope images (left: 2x2 mm², right 4x zoom)
1. *Dot spacing 0.05 mm*

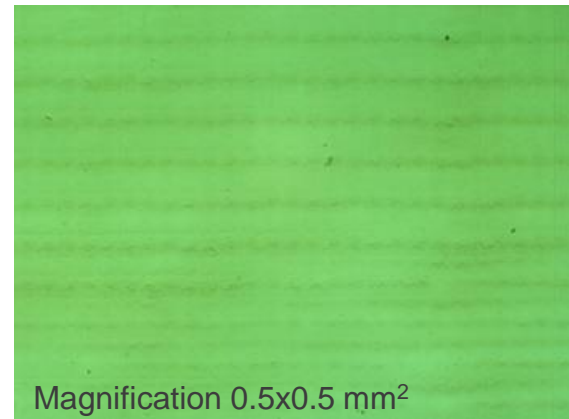
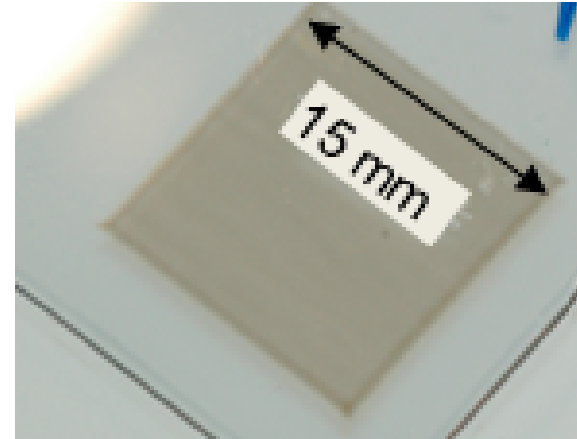
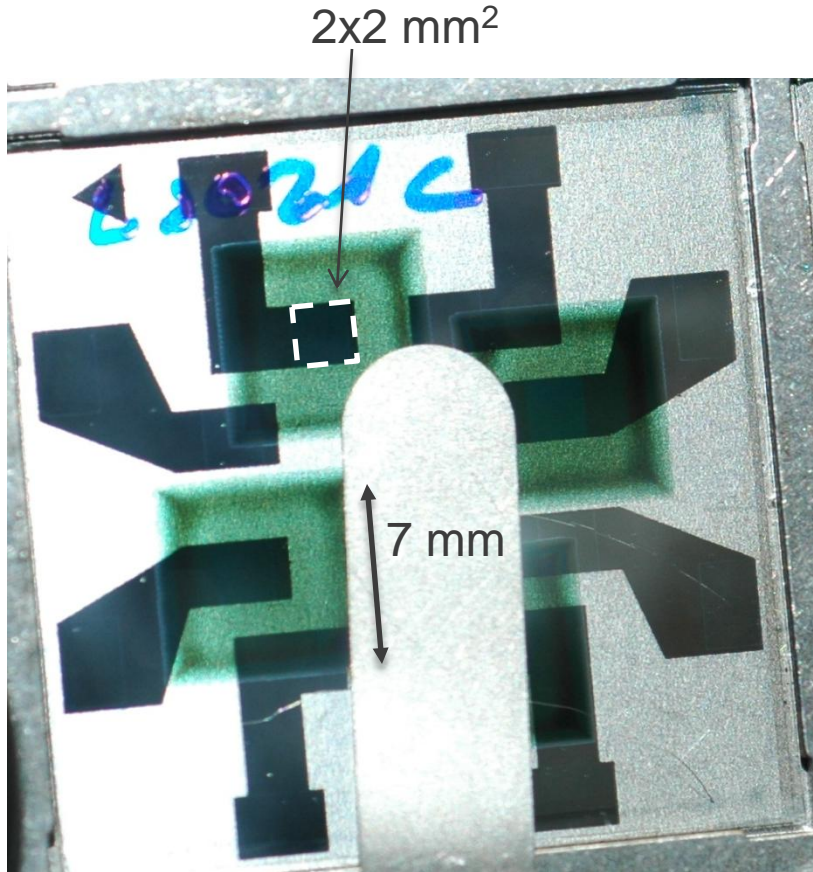


2. *Dot spacing 0.07 mm*



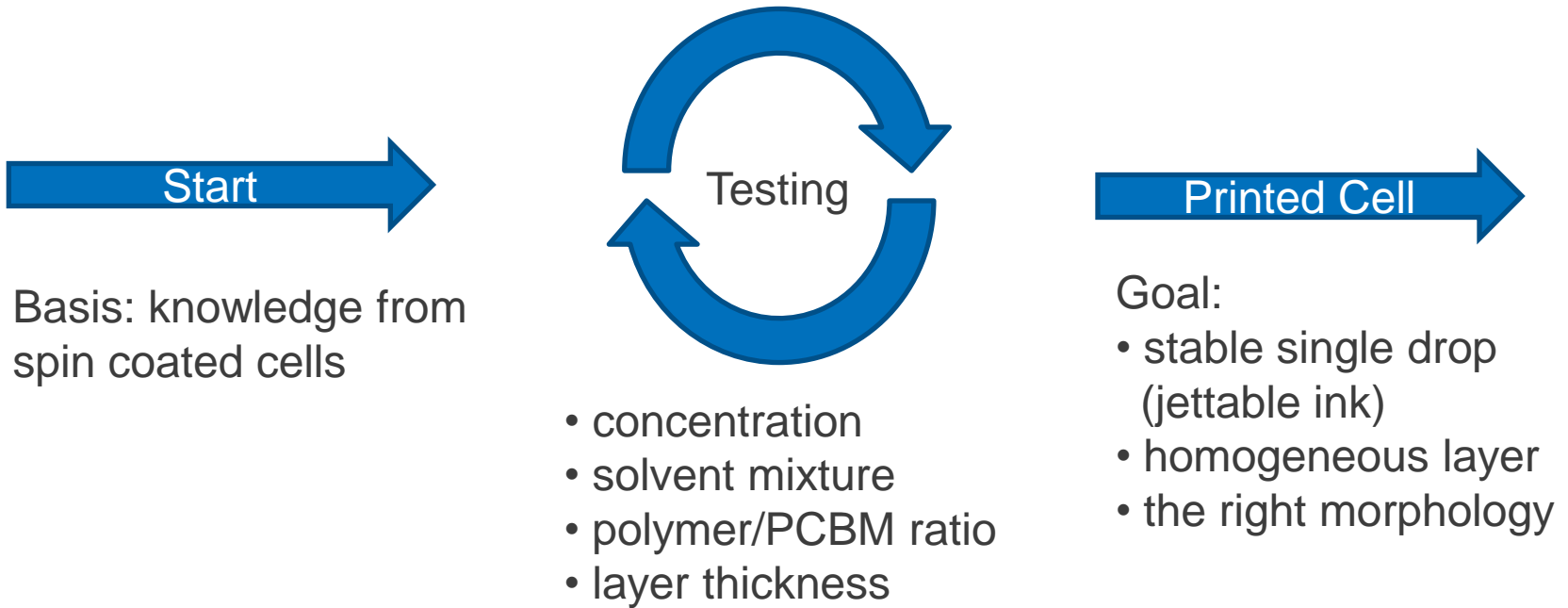
→
printing direction

Printed 2x2 mm² and 10x10 mm² devices



- Improvement in layer homogeneity
- Uniform 15x15 mm layers obtained by printing

Optimization

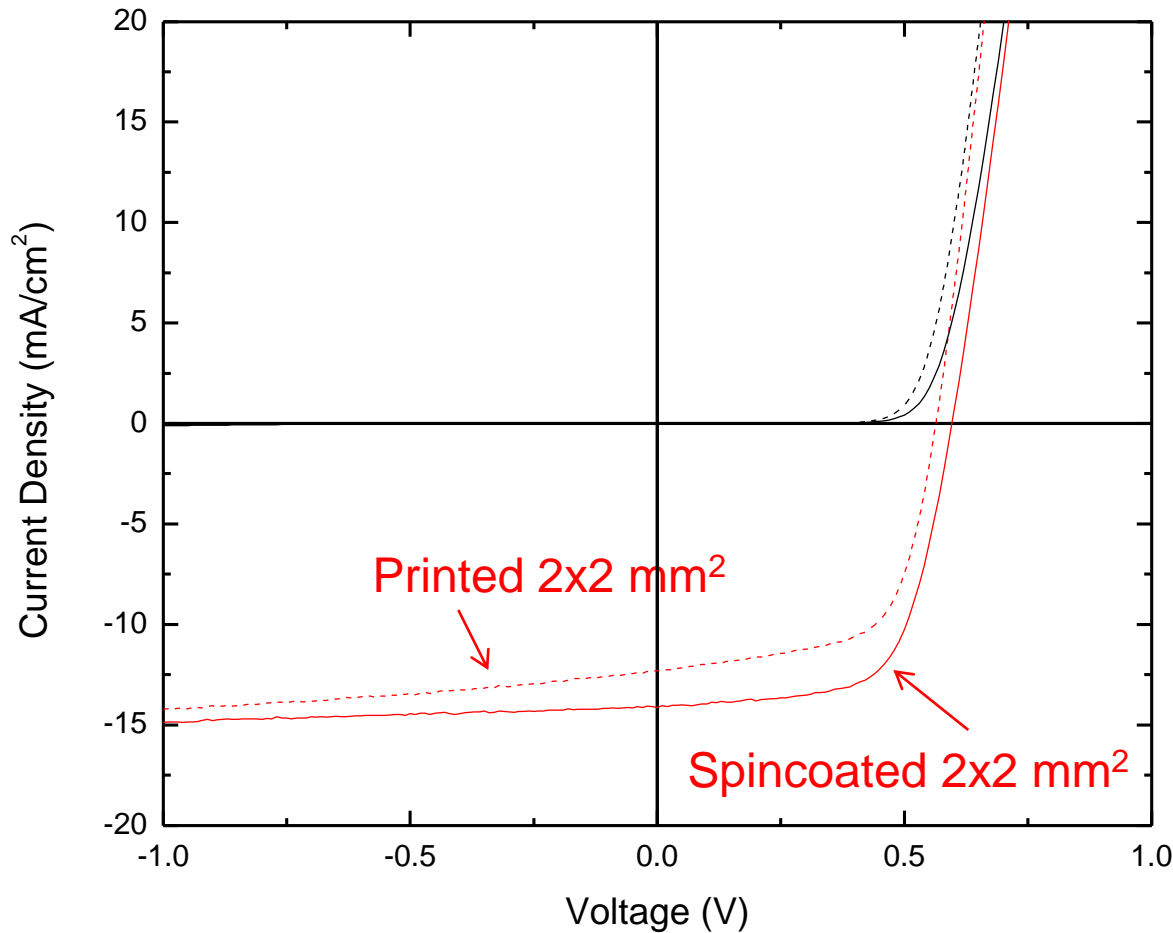


Optimization

- Spin coated cells:
 - PCBM:polymer ratio → optimal ratio: 1:2
 - chloroform:oDCB ratio → best results with 80:20
 - Layer thickness → optimal thickness: ~90 nm
- Printed cells
 - Printing of ratios $\geq 40:60$ resulted in clogging of nozzle
 - *Best printed cells sofar with 20:80 chloroform:oDCB*
 - Optimal thickness printed devices : ~140 nm
 - *Deposition method influences morphology*

Best results

2x2 mm²



Spincoated 90 nm

$$V_{oc} = 0.60 \text{ V}$$

$$J_{sc} = 14.1 \text{ mA/cm}^2 \text{ (uncorrected)}$$

$$FF = 0.65$$

$$mPP = 5.5 \text{ mW/cm}^2$$

Printed 140 nm

$$V_{oc} = 0.57 \text{ V}$$

$$J_{sc} = 12.3 \text{ mA/cm}^2 \text{ (uncorrected)}$$

$$FF = 0.63$$

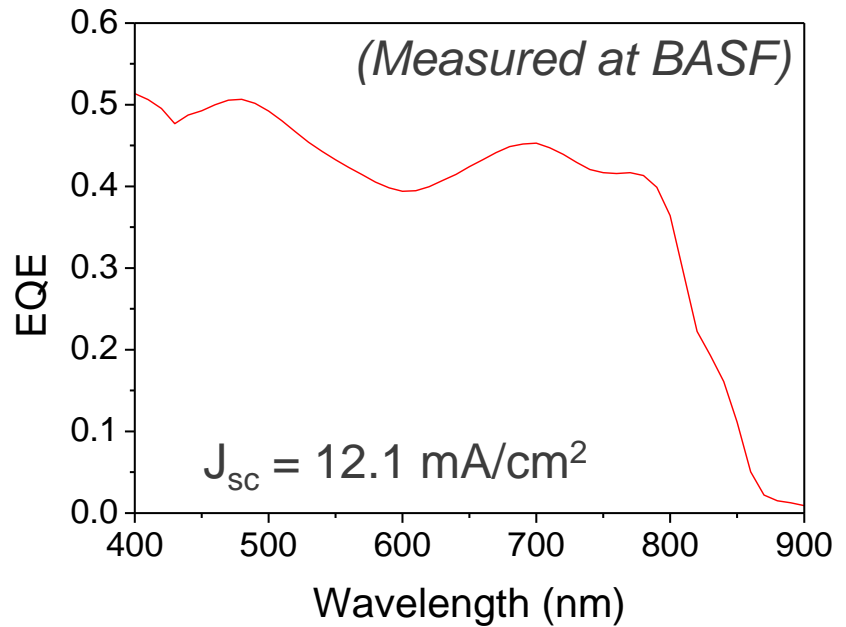
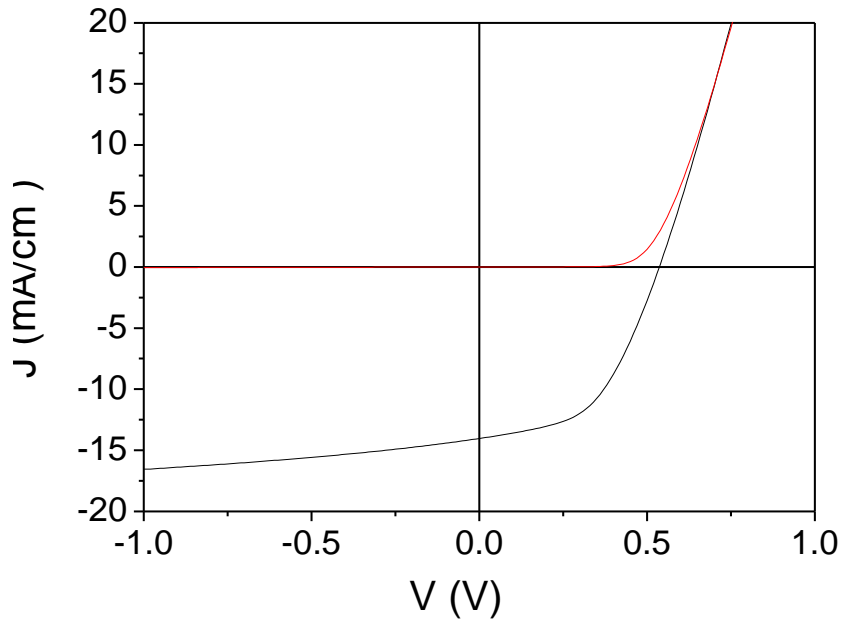
$$mPP = 4.4 \text{ mW/cm}^2$$

Estimated efficiency: 4%

benchmark: 3.5% *C. N. Hoth, Nano Letters, 8 (2008) 2806*

Best results

10x10 mm²



thickness = 150 nm

V_{oc} = 0.55 V

J_{sc} = 14.0 mA/cm² (12.1 mA/cm² corrected)

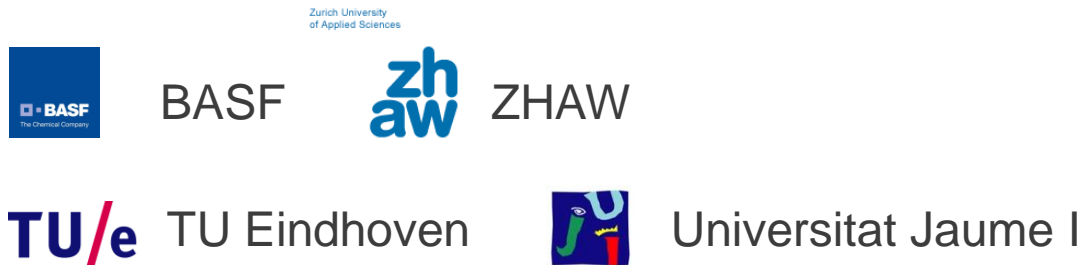
FF = 0.51

Efficiency: 3.4%

Acknowledgements

- At CSEM:
 - Basel: Jürg Schleuniger, Giovanni Nisato, Marek Chrapa, Guillaume Basset
 - Neuchatel: Olha Sereda, Antonia Neels, Nicolas Blondiaux, Véronique Monnier

- APOLLO project partners :



- Funding from Swiss Federal Office of Energy

Take home messages

CSEM:

- is an R&D company working with universities and industry
- is developing processes and technologies, also for organic electronics
- has presented ink-jet printed solar cells with 4% efficiency

Thank you for your attention!